



Docket No.: Micronas.6158

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: Czech et al.

GROUP:

2811

SERIAL NO: 09/852,122

EXAMINER: Unknown

FILED: 05/08/2001

FOR: ELECTROSTATIC DISCHARGE PROTECTIVE STRUCTURE
AND A METHOD FOR PRODUCING IT

Assistant Commissioner of Patents
Washington, D.C. 20231

Sir:

INFORMATION DISCLOSURE STATEMENT

In compliance with 37 C.F.R. §§1.56, 1.97, and 1.98, Applicant submits copies of the documents listed on the attached Form PTO-1449.

Respectfully submitted,

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I hereby certify that this paper (along with any paper referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to the Commissioner of Patents and Trademarks, Washington, D.C. 20

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**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
AA	5,543,649	08/06/1996	Kim et al.	257	355	03/01/1995
AB						
AC						
AD						
AE						
AF						
AG						
AH						

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
AI						
AJ						
AK						
AL						
AM						

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER INITIAL		
AN		
AO		

EXAMINER

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EXAMINER:

Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not consid red. Include c py of this form with n xt c mmunication to applicant.